	Application No.	Applicant(s)				
	Application No.	Applicant(s)				
Notice of Allowability	10/807,253	KENJI				
	Examiner	Art Unit				
	Douglas M. Menz	2891				
The MAILING DATE of this communication apper All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this apport or other appropriate communication GHTS. This application is subject to	plication. If not included				
1. This communication is responsive to <u>9/12/06</u> .						
2. The allowed claim(s) is/are <u>24-27</u> .						
3. ☐ Acknowledgment is made of a claim for foreign priority un a) ☐ All b) ☐ Some* c) ☐ None of the:						
1. Certified copies of the priority documents have been received.						
2. Certified copies of the priority documents have been received in Application No						
3. Copies of the certified copies of the priority documents have been received in this national stage application from the						
International Bureau (PCT Rule 17.2(a)).						
* Certified copies not received: Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application. THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.						
4. A SUBSTITUTE OATH OR DECLARATION must be submit INFORMAL PATENT APPLICATION (PTO-152) which give	itted. Note the attached EXAMINER's reason(s) why the oath or declara	S AMENDMENT or NOTICE OF tion is deficient.				
5. CORRECTED DRAWINGS (as "replacement sheets") mus	t be submitted.					
(a) ☐ including changes required by the Notice of Draftspers		948) attached				
1) 🗌 hereto or 2) 🔲 to Paper No./Mail Date		,				
(b) ☐ including changes required by the attached Examiner's Paper No./Mail Date	s Amendment / Comment or in the O	office action of				
Identifying indicia such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in the	84(c)) should be written on the drawir ne header according to 37 CFR 1.121(d	ngs in the front (not the back) of d).				
6. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.						
Attachment(e)						
Attachment(s) 1. ☐ Notice of References Cited (PTO-892)	5. Notice of Informal P	atent Application				
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. ☐ Interview Summary					
3. Information Disclosure Statements (PTO/SB/08),	Paper No./Mail Dat 7.	e				
Paper No./Mail Date4. Examiner's Comment Regarding Requirement for Deposit	8. Examiner's Stateme	nt of Reasons for Allowance				
of Biological Material	9. ⊠ Other <u>Updated Sear</u>	rch History				
	5. 23 Galler opadica ocal	<u></u>				

Art Unit: 2891

DETAILED ACTION

Allowable Subject Matter

Claims 24-27 are allowed.

The following is an examiner's statement of reasons for allowance:

There is no teaching or suggestion in the art of record disclosing an electrooptical device comprising all of the structural limitations of claim 24 in combination,
wherein the ultraviolet absorbing layer comprises a semiconductor material having
photocatalyst activity, wherein the semiconductor is selected from the group consisting
of titanium oxide, strontium titanate, tin oxide, niobium oxide, indium oxide, and gallium
oxide. Therefore, independent claim 24 is deemed allowable along with its dependent
claims 25-27.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Douglas M. Menz whose telephone number is 571-272-1877. The examiner can normally be reached on M-F 8-5.

Art Unit: 2891

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Bill Baumeister can be reached on 571-272-1722. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

DM

Doug Menz 11/27/06

Updated

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	2420	257/72.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/11/27 00:22
L2	1794	257/79.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/11/27 00:28
L3	532	(((electro adj optical) or el) with layer) and electrode and (light with absorbing) and barrier	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/11/27 00:32
L4	119	L3 and ((electro adj optical) or el).ab.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/11/27 00:32
L5	63	L4 and (ultraviolet or (ultra adj violet))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/11/27 00:32
L6	16	L5 and ((ultraviolet or (ultra adj violet)) with absorb\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/11/27 00:32
L7	15	6 and (titanium or strontium or tin or niobium or indium or gallium)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/11/27 00:33
L8	1	((electro-optical adj device) and (first adj electrode) and (second adj electrode) and (ultraviolet adj absorbing adj layer) and (absorbing with semiconductor) and ((gas adj barrier) with sequence)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/11/27 00:35